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(54) **Active matrix display device with storage capacitor for each pixel**

(57) An active matrix display device employing a top gate type TFT structure has a storage capacitor C_{sc} and a liquid crystal capacitor C_{lc} in each pixel of a pixel section, a first electrode (30) of the storage capacitor C_{sc} served by a p-Si active layer (14) of the TFT, and a second electrode (32) formed to at least partly overlap the active layer (14), with an insulating layer (12) between the active layer (14) and the second electrode (32) below it. When a driver section is to be built in, the driver section TFT is the same top gate type as the pixel section TFT, and an active layer (140) is made of the same

material as the active layer (14) and has a conductive layer (32D) which is made of the same material as the second electrode (32) with the insulating layer (12) held between the active layer (140) and the conductive layer (32D) below it. The pixel section can form the storage capacitor while preventing lowering of the aperture ratio. Because conditions for the polycrystallization annealing of the active layer are equal for the pixel section TFT and the driver section TFT, TFTs with the same properties can be obtained.

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**CLAIMS INCURRING FEES**

The present European patent application comprised at the time of filing more than ten claims.

- Only part of the claims have been paid within the prescribed time limit. The present European search report has been drawn up for the first ten claims and for those claims for which claims fees have been paid, namely claim(s):
- No claims fees have been paid within the prescribed time limit. The present European search report has been drawn up for the first ten claims.

LACK OF UNITY OF INVENTION

The Search Division considers that the present European patent application does not comply with the requirements of unity of invention and relates to several inventions or groups of inventions, namely:

see sheet B

- All further search fees have been paid within the fixed time limit. The present European search report has been drawn up for all claims.
- As all searchable claims could be searched without effort justifying an additional fee, the Search Division did not invite payment of any additional fee.
- Only part of the further search fees have been paid within the fixed time limit. The present European search report has been drawn up for those parts of the European patent application which relate to the inventions in respect of which search fees have been paid, namely claims:
- None of the further search fees have been paid within the fixed time limit. The present European search report has been drawn up for those parts of the European patent application which relate to the invention first mentioned in the claims, namely claims:

1-8, 12



The Search Division considers that the present European patent application does not comply with the requirements of unity of invention and relates to several inventions or groups of inventions, namely:

1. claims: 1-8, 12 (as far as depending on claims 1 to 8)

The special technical feature of dependent claim 5 (the first claim which makes a contribution over the prior art US 5956103) is the use of the gate line (20) as a conductive shielding layer (20e) in the region where the data line and the storage capacitor overlap (page 37, lines 6 to 19, and figures 14-15).

2. claims: 9-11, 12 (as far as depending on claims 9 to 11)

The special technical feature of independent claim 9 over the prior art US 5956103 is that at least a channel region (14c, figure 17) of the thin-film transistor is open (no electrode 32 of the storage capacitor under this region).

3. claims: 13-16

The special technical feature of independent claim 13 over the prior art US 5956103 is the disposition of a driver section and a pixel section on the same substrate (page 22, line 22 to page 23, line 11; figure 7).

ANNEX TO THE EUROPEAN SEARCH REPORT
ON EUROPEAN PATENT APPLICATION NO.

EP 02 25 2387

This annex lists the patent family members relating to the patent documents cited in the above-mentioned European search report. The members are as contained in the European Patent Office EDP file on The European Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

08-12-2004

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专利名称(译)	有源矩阵显示装置，每个像素带有存储电容		
公开(公告)号	EP1245996A3	公开(公告)日	2005-06-01
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其他公开文献	EP1245996A2		
外部链接	Espacenet		

摘要(译)

采用顶栅型TFT结构的有源矩阵显示装置在像素部分的每个像素中具有存储电容器Csc和液晶电容器Clc，存储电容器Csc的第一电极（30）由p-Si有源层服务（14）TFT，和形成至少部分地与有源层（14）重叠的第二电极（32），在其下方的有源层（14）和第二电极（32）之间具有绝缘层（12）。当要内置驱动器部分时，驱动器部分TFT是与像素部分TFT相同的顶部栅极类型，并且有源层（140）由与有源层（14）相同的材料制成并且具有导电性。层（32D）由与第二电极（32）相同的材料制成，绝缘层（12）保持在有源层（140）和位于其下方的导电层（32D）之间。像素部分可以形成存储电容器，同时防止孔径比的降低。因为像素部分TFT和驱动部分TFT的有源层的多晶化退火的条件相同，所以可以获得具有相同特性的TFT。

DOCUMENTS CONSIDERED TO BE RELEVANT		Reference to claims	CLASSIFICATION OF THE APPLICATION (ECLA/E)
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X	US 5 724 107 A (NISHIKAWA RYUJI ET AL) 3 March 1998 (1998-03-03) * column 1, line 1 - line 21 * * column 6, line 7 - line 22 * * figure 4 *	1, 12	TECHNICAL FIELDS SEARCHED (Int. Cl.) G02F

1 This pre-consultation report has been drawn up for all classes

1 The Hague 8 December 2004 Boubal, F

CATEGORY OF CITED DOCUMENTS
X particularly relevant to search
Y particularly relevant to examination
A document cited in the application
D document cited for other reasons
* non-written disclosure
* prior art document

I In reply to pre-grant underlying the invention
E In reply to pre-grant document, but not on the merits
D Document cited in the application
L Document cited for other reasons
A Document of the same patent family, corresponding document